

INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Attorney Docket Number	23-69853-01
	Application Number	10/727,062
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	First Named Inventor	John G. DeSteele
	Art Unit	1795
	Examiner Name	Jeffrey Thomas Barton

U.S. PATENT DOCUMENTS

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Examiner's Initials*	Cite No. (optional)	Number	Date	Name of Applicant or Patentee

FOREIGN PATENT DOCUMENTS

Examiner's Initials*	Cite No. (optional)	Country	Number	Date	Name of Applicant or Patentee

OTHER DOCUMENTS

Examiner's Initials*	Cite No. (optional)	
		Bottner, H., "Thermoelectric Micro Devices: Current State, Recent Developments and Future Aspects for Technological Progress and Applications," <i>Proc. 21st Int. Conf. Thermoelectronics, Long Beach, CA</i> , pp. 511-518 (August 25-29, 2002).
		Final Office action from the U.S. Patent and Trademark Office for U.S. Patent Application No. 10/726,744, dated April 13, 2009.
		Kim, D.-H. et al., "Effect of deposition temperature on the structural and thermoelectric properties of bismuth telluride thin films grown by co-sputtering," <i>Thin Solid Films</i> , Vol. 510, pp. 148-153 (2006).
		Office action from the U.S. Patent and Trademark Office in U.S. Patent Application No. 10/581,281, dated April 30, 2009.
		Sun, C.W. et al., "Crystallization behavior of non-stoichiometric Ge-Bi-Te ternary phase change materials for PRAM application," <i>J. Phys. Condens. Matter</i> , Vol. 19, 446004, 9 pages (2007).

EXAMINER SIGNATURE:	DATE CONSIDERED:
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